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Jiro KONDO, et al.

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GROUP

Not Yet Assigned

U. S. PATENT DOCUMENTS

EXAMINER INITIAL	PATENT/PUBLICATION NUMBER	PATENT/PUBLICATION DATE	NAME	CLASS	SUBCLASS	FILING DATE
	US	5,972,107	Schmid et al.		0/1999	
	US	6,368,403	Schmid et al.		4/2002	

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						Yes	No
/SC/	JP 56-32319 A	April 1, 1981	Japan			Partial	
/SC/	JP 58-130114 A	August 3, 1983	Japan			Partial	
/SC/	JP 2003-12317 A	January 15, 2003	Japan			Abstract	
/SC/	JP 4-130009 A	May 1, 1992	Japan			Abstract	
/SC/	JP 4-228414 A	August 18, 1992	Japan			Abstract	
/SC/	JP 5-246706 A	September 24, 1993	Japan			Abstract	
/SC/	JP 4-193706 A	July 13, 1992	Japan			Abstract	
/SC/	JP 9-202611 A	August 5, 1997	Japan			Abstract	
/SC/	WO 89/02415	March 23, 1989	PCT				

OTHER DOCUMENTS

EXAMINER INITIAL	AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.
/SC/	Mitsuru Tanahashi et al., Distribution Behavior of Boron Between SiO ₂ -saturated NaO _{2.5} -CaO-SiO ₂ Flux and Molten Silicon, Journal of the Mining and Materials, Processing Institute of Japan, Vol. 118, No. 7, Pages 497-505, 2002

EXAMINER /Stefanie Cohen/	DATE CONSIDERED 07/18/2008
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